

Serial No.: 10/714,994
Inventor(s): Morin et al.

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U.S. PTO Customer No. 25280
Case No.: 5150A

AMENDMENTS TO THE CLAIMS

1-28. (Cancelled)

29. (Currently amended) An article comprising:

a base substrate having a first side and a second side;

a plurality of receiving loop yarns extending from the first side of said base substrate, the receiving loop yarns comprising a multi-filament yarn; and,

a plurality of stiff loop yarns extending from the first side of said base substrate, each of said plurality of stiff loop yarns comprising a monofilament yarn having a denier per filament of at least about 10 denier per filament greater than the multi-filament yarns of the receiving loop yarns, wherein the stiff loop yarns are stiffer than the receiving loop yarns, and;

wherein the receiving loop[[s]] yarns and the stiff loop[[s]] yarns originate at the same origination location on the first side of the base substrate and return to the first side of the base substrate at the same return location to form first receiving loops and first stiff loops, wherein the origination location and the return location for each first receiving and first stiff loop are separated by about 0.1 to 5 millimeters along the base substrate, and wherein the first stiff loops are higher than and separate from the first receiving loops.

30. (Previously presented) The article according to Claim 29, wherein the stiff loop yarns include a cross-section having at least one corner edge.

31. (Previously presented) The article according to Claim 29, wherein the stiff loop yarns include a cross-section having an aspect ratio of greater than 1:2.

33. (Previously presented) The article according to Claim 29, wherein the stiff loop yarns comprise a slit film.

34. (Previously presented) The article according to claim 29, wherein the stiff loop yarns have a cross-sectional area that is selected from the group consisting of square shaped, rectangular shaped, tear drop shaped, crescent shaped, multi-lobe shaped, and concave shaped.

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35. (Cancelled)

36. (New) The article according to claim 29, further comprising:

a base substrate having a first side and a second side;

a plurality of second receiving loop yarns extending from the second side of said base substrate, the second receiving loop yarns comprising a multi-filament yarn;

a plurality of second stiff loop yarns extending from the second side of said base substrate, each of said plurality of second stiff loop yarns comprising a monofilament yarn having a denier per filament of at least about 10 denier per filament greater than the multi-filament yarns of the second receiving loop yarns, wherein the second stiff loop yarns are stiffer than the second receiving loop yarns;

wherein the second receiving loop yarns originate an origination location on the second side of the base substrate and return to the second side of the base substrate at a return location on the second side of the base substrate, wherein the second stiff loops originate an origination location on the second side of the base substrate and return to the second side of the base substrate at a return location on the second side of the base substrate, and wherein the second stiff loops are higher than and separate from the second receiving loops.

37. (New) The article according to claim 36, wherein the second receiving loop yarns and the second stiff loop yarns originate at the same origination location on the second side of the base substrate and return to the second side of the base substrate at the same return location, and wherein the origination location and the return location are separated by about 0.1 to 5 millimeters along the base substrate.

38. (New) The article according to claim 37, wherein the origination locations on the first side of the base substrate and the origination locations on the second side of the base substrate are located at the same points along the base substrate, and wherein the return locations on the first side of the base substrate and the return locations on the second side of the base substrate are located at the same points along the base substrate.